# AI-Nb-Si (Aluminum-Niobium-Silicon)

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Recently, [2004Sha] presented a thermodynamic assessment of this system and computed a liquidus projection and two isothermal sections at 1400 and 1000 °C. The available experimental data on the isothermal sections show good agreement with the computed sections.

## **Binary Systems**

The Al-Nb phase diagram [Massalski2] has three intermediate phases: NbAl<sub>3</sub> ( $DO_{22}$ , TiAl<sub>3</sub>-type tetragonal), Nb<sub>2</sub>Al (30-42 at.% Al;  $DB_b$ ,  $\sigma$ CrFe-type tetragonal), and Nb<sub>3</sub>Al (18.6-25 at.% Al; A15, Cr<sub>3</sub>Si-type cubic). The Al-Si system is of the simple eutectic type, with the eutectic temperature at 577 °C and the composition at 12.2 at.% Si. The Nb-Si phase diagram [1993Sch, 1995Sch] has the following intermediate phases. Nb<sub>3</sub>Si (Ti<sub>3</sub>P-type tetragonal),  $\beta$ Nb<sub>5</sub>Si<sub>3</sub> (*D*8<sub>*m*</sub>, W<sub>5</sub>Si<sub>3</sub>-type tetragonal),  $\alpha$ Nb<sub>5</sub>Si<sub>3</sub> (*D*8<sub>*m*</sub>, Cr<sub>5</sub>Si<sub>3</sub>-type tetragonal), and NbSi<sub>2</sub> (*C*40, CrSi<sub>2</sub>-type hexagonal).

# **Ternary Phases**

Two ternary phases have been identified in this system [1961Bru]. Al<sub>2</sub>Nb<sub>3</sub>Si<sub>5</sub> (denoted  $\tau_1$  here) has the C54, TiSi<sub>2</sub>-

### Table 1 Al-Nb-Si crystal structure and lattice parameter data

Phase	Composition, at.%	Pearson symbol	Space group	Prototype	Lattice parameter, nm
$Al_2Nb_3Si_5\;(\tau_1)$	~20 Al	oF24	Fddd	TiSi <sub>2</sub>	a = 0.8403
	~30 Nb				b = 0.4901
	~50 Si				c = 0.8794
$Al_{3}Nb_{10}Si_{3}\left( \tau _{2}\right)$	~18.75 Al	tI 32	I4/mcm	W <sub>5</sub> Si <sub>3</sub>	a = 1.016
	~62.5 Nb				c = 0.508
	~18.75 Si				



Fig. 1 Al-Nb-Si computed isothermal section at 1400 °C [2004Sha]



Fig. 2 Al-Nb-Si computed isothermal section at 1000 °C [2004Sha]

type orthorhombic structure, with a small homogeneity range at constant Nb content. The other compound Al<sub>3</sub>Nb<sub>10</sub>Si<sub>3</sub> (denoted  $\tau_2$  here and  $\beta$  by [2004Sha]) has the  $D8_m$ -type tetragonal structure of  $\beta$ Nb<sub>5</sub>Si<sub>3</sub>. It is apparently stabilized by Al substituting for Si. It is stable at 1400 °C as a ternary phase, even though the decomposition temperature of  $\beta$ Nb<sub>5</sub>Si<sub>3</sub> in the binary system is 1650 °C.  $\tau_2$  was not found at 1000 °C by [2003Zha].

## **Isothermal Sections**

The experimental investigations of this system are [1961Bru] (a composite isothermal section at 1400 °C for Nb-rich alloys and at 500 °C for Nb-poor alloys), [1973All] (partial isothermal sections for Nb-poor alloys at 1500 and 1300 °C), [1984Pan] (partial isothermal section at 1500 °C for Nb-rich alloys), [2001Mur] (isothermal section valid between 1600-1200 °C), and [2003Zha] (isothermal section at 1000 °C). For the isothermal sections of [1961Bru], [1973All], and [1984Pan], see [1995Vil]. [2001Mur] used powders of 99.9% Al, 99.8% Nb, and 99.9% Si to prepare samples by compacting and sintering in the temperature range of 1200-1600 °C for 0.3-0.6 ks. They confirmed the presence of the two ternary compounds  $\tau_1$  and  $\tau_2$  and drew a tentative isothermal section valid for the above temperature range. Crystallographic data for these two ternary phases are given in Table 1. Using a diffusion-multiple approach, [2003Zha] constructed an isothermal section at 1000 °C, which depicts the ternary phase  $\tau_1$ . The Al-stabilized  $\beta Nb_5 Si_3$ -based ternary phase ( $\tau_2$ ) was not found at this temperature. Tie-lines form between  $\alpha Nb_5 Si_3$  and NbAl<sub>3</sub>, confirming the results of [1984Pan] and [2001Mur]. The Al solubility in  $\alpha Nb_5 Si_3$  is ~8 at.%, with the Al atoms substituting for Si.

[2004Sha] developed a thermodynamic description of this system using the CALPHAD approach. For the Al-Nb and Al-Si systems, the earlier descriptions from the literature were used. The Nb-Si system was reoptimized by [2004Sha], using a term for the excess entropy of mixing of the liquid phase. The computed isothermal sections at 1400 and 1000 °C are redrawn in Fig. 1 and 2. [2004Sha] found good agreement with the experimental data of [1961Bru], [2001Mur], and [2003Zha]. [2004Sha] computed a liquidus projection, which depicts that  $\tau_1$  and  $\alpha Nb_5Si_3$  form peritectically in the ternary region. There are no experimental data to compare with the computed projection.

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